



IFW

### Amendment

#### TECHTOR INTERNATIONAL SERVICES

20775 Norada Court  
Saratoga, CA 95070-3018  
Docket No. 2001076  
Customer No: 47625

#### Certificate of Mailing

Date: December 2, 2005

I hereby certify that the attached document, 11 pages, is being deposited with the United States Postal Service as first class mail with sufficient postage under 37 CFR 1.8 on the date indicated above addressed to:  
Mail Stop Amendments Commissioner of Patents, PO Box 1450  
Alexandria, VA 22313-1450.

by: Ralph H. Willgohe  
Registration Number: 48,800

#### IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of Peter WANG  
Serial No. 10/777,417  
Filed: 2/11/2004  
For: "Method of Exposure Error Adjustment in Photolithography for Multiple Products"

Examiner: Nguyen, Hung

Group Art Unit: 2851

#### Amendment

#### THE COMMISSIONER OF PATENTS AND TRADEMARKS

Alexandria, VA 22313-1450

Sir:

Transmitted herewith is an amendment in the above-identified application.

- ☐ Enclosed herewith is a petition to extend time to respond.  
☒ Small entity status of this application under 37 CFR §§1.9 and 1.27 has been established previously.  
☐ A statement to establish small entity status under 37 CFR §§1.9 and 1.27 is enclosed.

The claims fee has been calculated as shown below:

	CLAIMS REMAINING AFTER AMENDMENT		HIGHEST NUMBER PREVIOUSLY PAID FOR	PRESENT EXTRA
TOTAL	17	MINUS *	20	= 0
INDEP.	3	MINUS **	3	= 0
] FIRST PRESENTATION OF MULTIPLE DEP. CLAIM				

\* Minimum of 20

\* Minimum of 3

☒ No fee is due.

☐ Enclosed is a check for \$\_\_\_\_\_

#### SMALL ENTITY

RATE	ADDIT. FEE
X25=	\$ 0
X100=	\$ 0
+180=	\$ 0
TOTAL ADDIT. FEE	\$ 0

OR

#### OTHER THAN A SMALL ENTITY

RATE	ADDIT. FEE
X50=	\$
X200=	\$
+360=	\$
TOTAL ADDIT. FEE	\$

OR

Respectfully Submitted,

Ralph Willgohe  
Reg. No. 48,800



Amendment

Pro-TECHTOR INTERNATIONAL SERVICES

20775 Norada Court

Saratoga, CA 95070-3018

Docket No. 2001076

Customer No: 47625

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Amendment

Commissioner of Patents and Trademarks

Alexandria, VA 22313-1450

Sir:

In response to the Office Action mailed September 2, 2005, please amend the application as follows. This amendment responds to the Examiner's rejections expressed in the Office Action. Reconsideration and allowance of the claims are respectfully requested for the reasons set forth below.

Please amend the application as follows, deletions are shown by strikethrough, and additions are shown underlined.

Applicant submits that these amendments are clarifications of material already present or inherent in the original application and do not represent new material.

Amendments to the Specification begin on page 2.

Amendments to the Claims begin on page 6.

Remarks begin on page 9.